

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S63	186	active near2 circuit and silicon near2 oxynitride and polyimide near2 (layer film)	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/08 14:02
S64	89	active near2 circuit and silicon near2 oxynitride and polyimide near2 (layer film)	USPAT; EPO; JPO	OR	ON	2005/12/08 14:02